



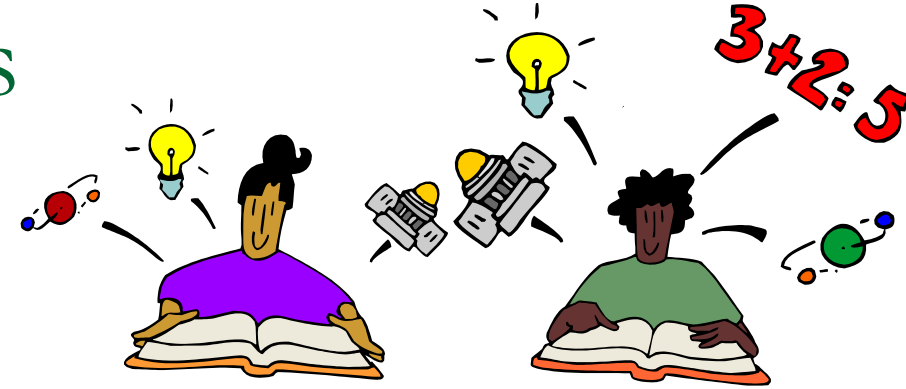
## ECEG-2131 (AEI): Carrier Transport and PN junction

Addis Ababa Institute of Technology (AAIT) School of Electrical and  
Computer Engineering

Addis Ababa  
University  
(Since 1950)



# Learning Outcomes

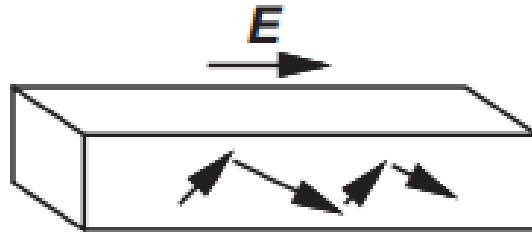


- At the end of the lecture, students should be able to know about:
  - ❑ Drift Current.
  - ❑ Diffusion Current
  - ❑ Resistivity of a material
  - ❑ Conductivity of a material
  - ❑ The PN junction

# Carrier Transport

- Having studied charge carriers and the concept of doping, we are ready to examine the movement of charge in semiconductors, i.e., the mechanisms leading to the flow of current.
- ***Current = Drift + Diffusion***

Drift Current



$$J_n = q n \mu_n E$$

$$J_p = q p \mu_p E$$

Diffusion Current

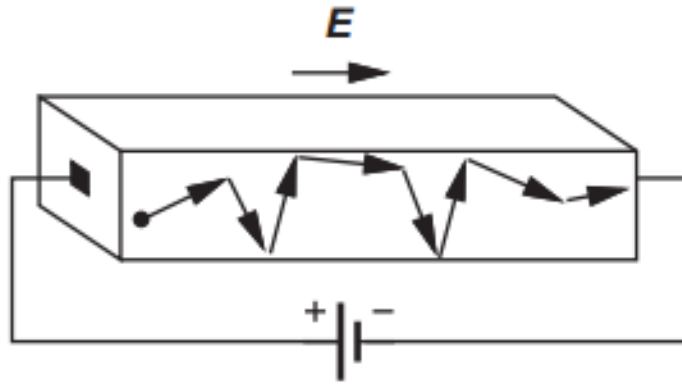


$$J_n = q D_n \frac{dn}{dx}$$

$$J_p = -q D_p \frac{dp}{dx}$$

# Drift

- **Drift** it is the movement of charge carriers due to an electric field.



- Charge carriers are accelerated by the field and accidentally collide with the atoms in the crystal, eventually reaching the other end and flowing into the battery.
- The acceleration due to the field and the collision with the crystal counteract, leading to a constant velocity for the carriers.

# Drift

- We expect the velocity,  $v$ , to be proportional to the electric field strength,  $E$ :

$$v \propto E,$$

$$v = \mu E,$$

- Where  $\mu$  is called the “mobility”. For example in silicon, the mobility of electrons,  $\mu_n = 1350 \text{ cm}^2/(\text{V}\cdot\text{s})$ , and that of holes,  $\mu_p = 480 \text{ cm}^2/(\text{V}\cdot\text{s})$ .
- For electrons and holes, we can rewrite the formula as follows:

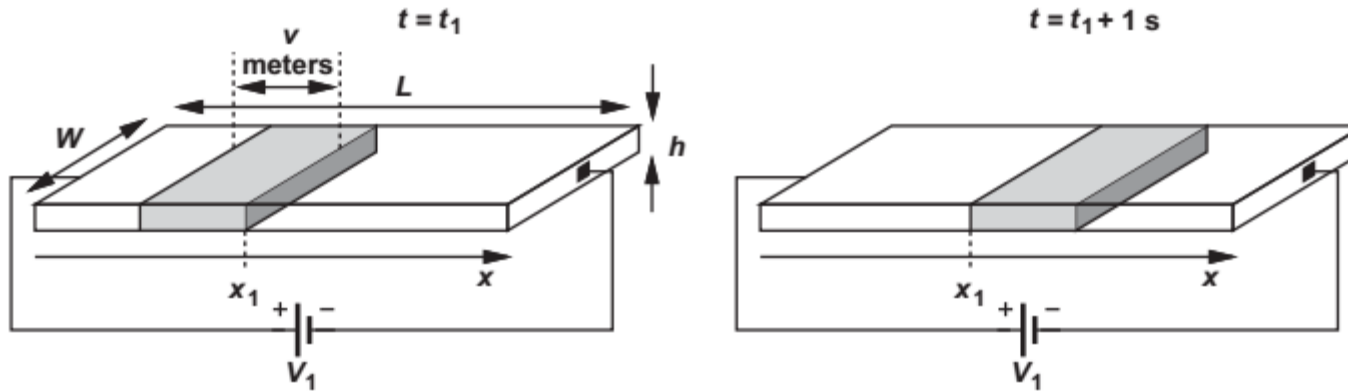
$$\vec{v}_e = -\mu_n \vec{E}.$$

$$\vec{v}_h = \mu_p \vec{E}.$$

- So, how can we calculate the current due to drift based on the drift velocity?



# Drift



- We can calculate the total charge passing through in 1 second as follows,

$$I = -v \cdot W \cdot h \cdot n \cdot q$$

- The corresponding current density due to electrons is given by,

$$J_{tot} = \mu_n E \cdot n \cdot q + \mu_p E \cdot p \cdot q$$

$$= q(\mu_n n + \mu_p p)E.$$

The conductivity  $\sigma$  of a semiconductor  $\sigma = nq_n\mu_n + pq_p\mu_p$



# Exercise

- Compute the conductivity of an intrinsic Silicon. Assuming  $n = p = n_i = 1.5 \times 10^{16} \text{ carriers/m}^3$ ,  $\mu_n = 0.14 \text{ m}^2/(\text{V} \cdot \text{s})$  and  $\mu_p = 0.05 \text{ m}^2/(\text{V} \cdot \text{s})$

$$\sigma = nq_n\mu_n + pq_p\mu_p$$

$$\sigma = n_i q (\mu_p + \mu_n)$$

$$\sigma = (1.5 \times 10^{16})(1.6 \times 10^{-19})(0.14 + 0.05)$$

$$\sigma = 4.56 \times 10^{-4} \text{ S/m}$$





# Exercise

- A bar of silicon with intrinsic electron density  $1.4 \times 10^{16}$  electrons/m<sup>3</sup> is doped with impurity atoms until the hole density is  $8.5 \times 10^{21}$  holes/m<sup>3</sup>.
- Find the electron density of the extrinsic material

$$n = \frac{n_i^2}{p} = \frac{(1.4 \times 10^{16})^2}{8.5 \times 10^{21}} = 2.3 \times 10^{10} \text{ electrons/m}^3$$

- Is the extrinsic material n-type or p-type

Since  $p > n$ , the material is p-type.

- Find the extrinsic conductivity

$$\sigma = nq_n\mu_n + pq_p\mu_p$$

$$\sigma = (2.3 \times 10^{10})(0.14)(1.6 \times 10^{-19}) + (8.5 \times 10^{21})(0.05)(1.6 \times 10^{-19})$$

$$\sigma = 5.152 \times 10^{-10} + 68 \approx 68 \text{ S/m}$$



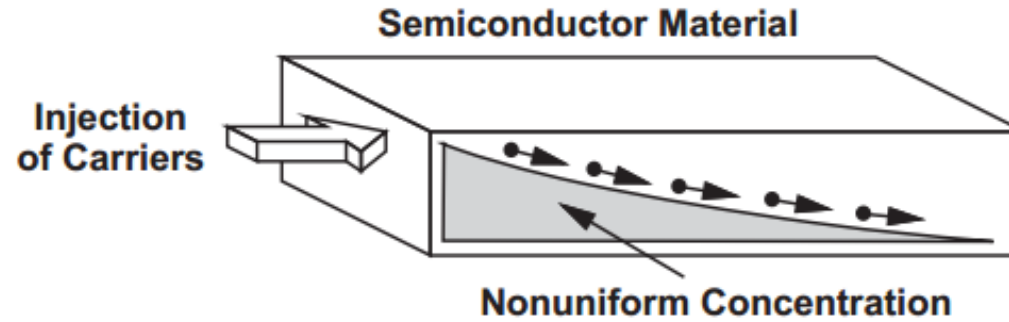


# Diffusion

- In addition to drift, another mechanism can lead to current flow.
- If charge carriers are “dropped” (injected) into a semiconductor it creates a nonuniform density of charge carriers.
- This high concentration of the injected carriers tend to flow from the region of high concentration to regions of low concentration.
- This mechanism is known as “**diffusion**”.
- Even in the absence of an electric field, the carriers move toward regions of low concentration, thereby carrying an electric current so long as the nonuniformity is sustained.



# Diffusion



- From what we know qualitatively, the more nonuniform the concentration the more the current. Hence,

$$I \propto \frac{dn}{dx}$$

- We call  $dn/dx$  the concentration gradient with respect to  $x$ . If each carrier has a charge equal to  $q$  and the semiconductor has a cross sectional area of  $A$ ,

$$I \propto Aq \frac{dn}{dx}.$$

# Diffusion

- Therefore the total current will be given by,

$$I = AqD_n \frac{dn}{dx},$$

- Where  $D_n$  is a proportionality factor called the “diffusion constant”.
- In intrinsic Silicon,  $D_n = 34\text{cm}^2/\text{s}$  (for electrons), and  $D_p = 12\text{cm}^2/\text{s}$  (for holes).
- The corresponding current density then becomes:

$$J_n = qD_n \frac{dn}{dx}, \quad J_p = -qD_p \frac{dp}{dx}.$$

$$J_{tot} = q \left( D_n \frac{dn}{dx} - D_p \frac{dp}{dx} \right).$$



# Einstein Relation

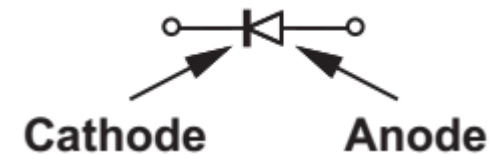
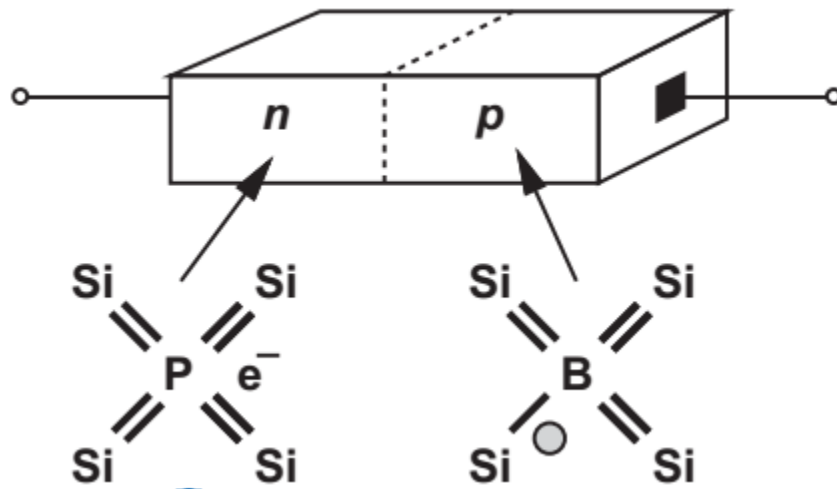
- From our discussions, we have seen two types of currents of a semiconductor.
- These have introduced factors  $\mu_n$  (or  $\mu_p$ ) and  $D_n$  (or  $D_p$ ) for drift and diffusion respectively.
- They can be related using the Einstein relation,

$$\frac{D}{\mu} = \frac{kT}{q}$$



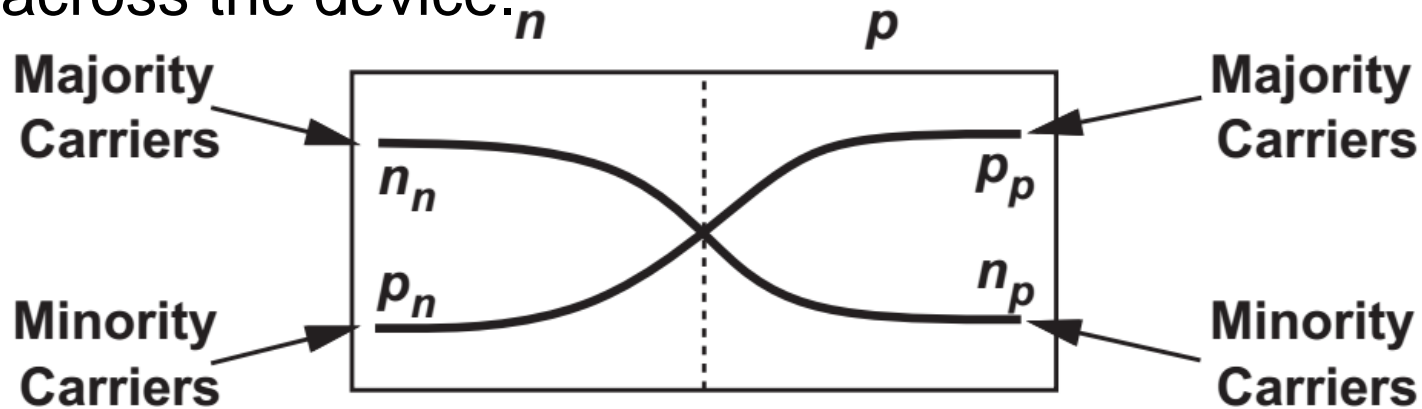
# $pn$ Junction

- An interesting situation arises when we introduce n-type and p-type dopants into two adjacent sections of a piece of semiconductor.
- We can only build this device on a single crystal, i.e. we can't bring a separate n-type material and p-type material together.
- This device finds applications in many electronic devices



# $pn$ junction in equilibrium

- With no external connections, i.e. the terminals are open and no voltage is applied across the device.



$n_n$  : Concentration of electrons on n side

$p_n$  : Concentration of holes on n side

$p_p$  : Concentration of holes on p side

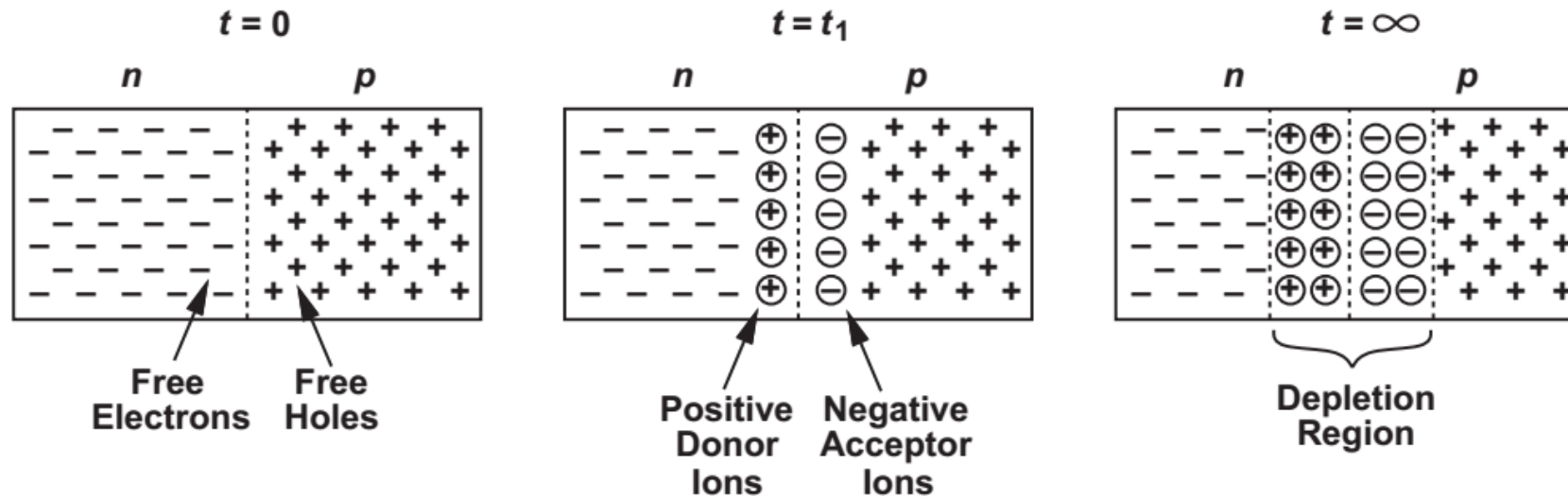
$n_p$  : Concentration of electrons on p side

- There is an initial diffusion of majority carriers from both sides.



# $pn$ junction in equilibrium

- Initially there is a diffusion of carriers from both sides.

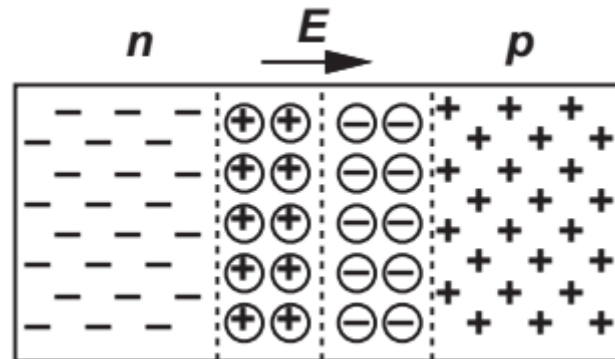


- This diffusion eventually decays to zero.
- For every electron that departs from the  $n$  side, a positive ion is left behind.
- The immediate vicinity of the junction is depleted of free carriers and hence called the "depletion region".



# $pn$ junction in equilibrium

- Because of the ions left in the depletion region, an electric field is generated.
- Hence, we have a drift current which opposes the diffusion current.



- The junction reaches equilibrium once the electric field is strong enough to completely stop the diffusion current.

# $pn$ junction in equilibrium

- In equilibrium, we must impose this condition,

$$|I_{\text{drift},p}| = |I_{\text{diff},p}|$$

- From this, we get:

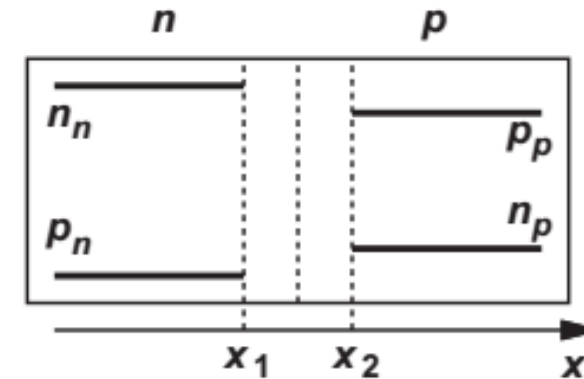
$$|I_{\text{drift},n}| = |I_{\text{diff},n}|.$$

$$q\mu_p p E = qD_p \frac{dp}{dx}$$

- Finally,

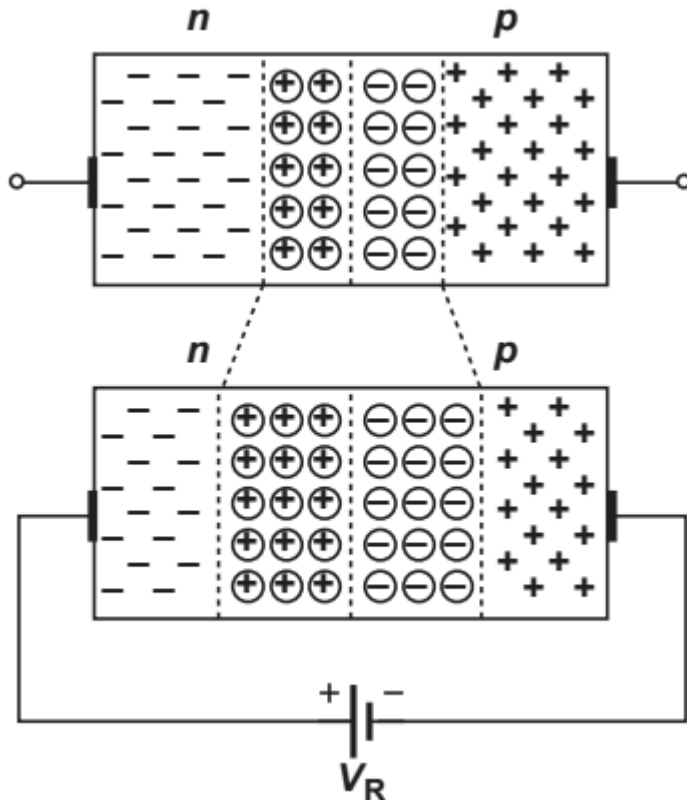
$$V(x_2) - V(x_1) = -\frac{D_p}{\mu_p} \ln \frac{p_p}{p_n}.$$

$$|V_0| = \frac{kT}{q} \ln \frac{p_p}{p_n} \quad \text{or} \quad V_0 = \frac{kT}{q} \ln \frac{N_A N_D}{n_i^2}$$

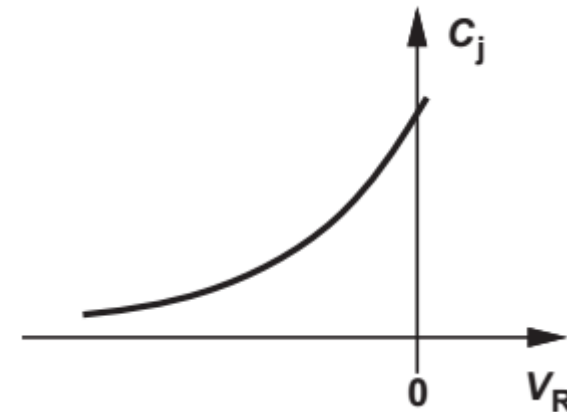


# $pn$ junction under reverse bias

- We first apply a voltage source that makes the n side more positive and the p side more negative, i.e. reverse bias

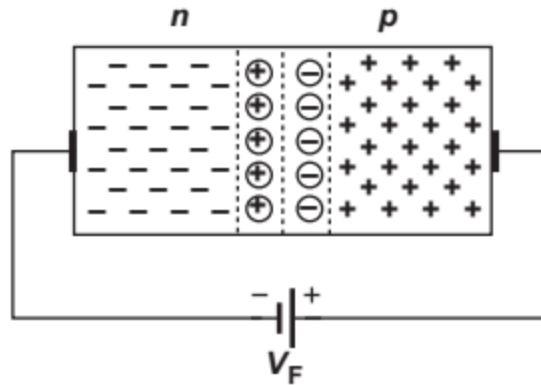


$$C_j = \frac{C_{j0}}{\sqrt{1 - \frac{V_R}{V_0}}}$$



# $pn$ junction under forward bias

- We can also apply a voltage that makes the p side more positive and the n side more negative, i.e. forward bias



- This is also known as the diode.

# What to Do This Week?

- Reading Assignment
  - Diode modeling
  - Diode circuits
  - Diode applications

